REMARKS

The requirement for restriction being the only issue raised in the present Office Action, this paper is fully responsive to the same. The Applicants hereby reserve the right to file a divisional application for any non-elected subject matter in this application.

In the event the Examiner has any queries regarding the presently submitted response, the undersigned respectfully requests the courtesy of a telephone conference to discuss any matters in need of attention. If there are any associated or additional charges with respect to this Response or otherwise, please charge them to Deposit Account No. 06-1130 maintained by Applicants' attorney.

Respectfully submitted,

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Date: August 17, 2004

BEFORE THE OFFICE OF ENROLLMENT AND DISCIPLINE UNITED STATE PATENT AND TRADEMARK OFFICE

LIMITED RECOGNITION UNDER 37 CFR § 10.9(b)

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Expires: December 2, 2004

Harry I. Moatz

Director of Enrollment and Discipline